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FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/26/2003	Khiem K. Nguyen	Khiem K. Nguyen AMAT/8349/MASK/ETEC/ARNOL 8442 EXAMINER		
7590 10/12/2005				
PATTERSON & SHERIDAN, LLP		KACKAF	KACKAR, RAM N	
3040 POST OAK BOULEVARD, SUITE 1500 HOUSTON, TX 77056	ITE 1500	ART UNIT	ART UNIT PAPER NUMBER 1763	
		1763		
	09/26/2003 7590 10/12/2005 ON & SHERIDAN, LL DAK BOULEVARD, SU	09/26/2003 Khiem K. Nguyen 7590 10/12/2005 ON & SHERIDAN, LLP OAK BOULEVARD, SUITE 1500	09/26/2003 Khiem K. Nguyen AMAT/8349/MASK/ETEC/ARI 7590 10/12/2005 EXAM N & SHERIDAN, LLP KACKAR OAK BOULEVARD, SUITE 1500 TX 77056	

DATE MAILED: 10/12/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary		Application No.	Applicant(s)			
		10/672,420	NGUYEN ET AL.			
		Examiner	Art Unit			
		Ram N. Kackar	1763			
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with th	e correspondence address			
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Depriod for reply is specified above, the maximum statutory period we are to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION ATE OF THIS COMMUNICA	ON. e timely filed from the mailing date of this communication. ENED (35 U.S.C. § 133).			
Status						
1)⊠	Responsive to communication(s) filed on <u>26 September 2003</u> .					
2a)□	This action is FINAL . 2b)⊠ This action is non-final.					
3)□						
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11,	453 O.G. 213.			
Disposit	ion of Claims					
4)🖾	4) Claim(s) 1-22 is/are pending in the application.					
	4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠	6)⊠ Claim(s) <u>1-22</u> is/are rejected.					
7)[_	, <u> </u>					
8)	Claim(s) are subject to restriction and/or	election requirement.				
Applicati	ion Papers					
9)[The specification is objected to by the Examiner	r.				
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)	The oath or declaration is objected to by the Ex	aminer. Note the attached Offic	ce Action or form PTO-152.			
Priority u	ınder 35 U.S.C. § 119					
a)[Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priorical application from the International Bureausee the attached detailed Office action for a list of	have been received. have been received in Applicate ty documents have been received (PCT Rule 17.2(a)).	ation No ived in this National Stage			
Attachment	• ,	🗖				
1) 🔀 Notice of References Cited (PTO-892) 4) 🔲 Interview Summary (PTO-413) 2) Dotice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date						
3) 🔯 Inforn Paper	nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) No(s)/Mail Date <u>01/05/2004</u> .		I Patent Application (PTO-152)			
Attachment X Notice Notice Notice Notice Notice Notice	t(s) e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	4) ☐ Interview Summa Paper No(s)/Mail 5) ☐ Notice of Informal	nry (PTO-413) Date			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-2, 4-6, 8-16 and 21-22 are rejected under 35 U.S.C. 102(b) as being anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Herchen et al (US 6159297).

Herchen et al disclose a process chamber (Fig 1) comprising a substrate support member (30), an interferometer end point detection system (175 and Col 9 lines 5-35) mounted above and configured to detect a peripheral region of the substrate (Fig 1). Further the interferometer end point system comprises a light source and a light detector (Col 10 lines 18-65) and a computer for calculating a spectra (Col 10 line 65 to Col 11 line10) and comparing to a stored characteristic value to determine the endpoint.

3. Claims 1-2, 4-14, 16, 18 and 21-22 are rejected under 35 U.S.C. 102(b) as being anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Yohei Yamazawa (JP 2001217227).

Yohei Yamazawa disclose a process chamber (Fig 1) comprising a substrate support member (12), an interferometer end point detection system (Abstract) mounted above and configured to detect a peripheral region of the substrate (Fig 1). Further the interferometer end

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point system comprises a light source and a light detector (23,22) and a computer for calculating a spectra (26 and 27).

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 3, 17 and 19-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Herchen et al (US 6159297) in view of Mihashi et al (JP 11058225).

Herchen et al disclose a process chamber (Fig 1) comprising a substrate support member (30), an interferometer end point detection system (175 and Col 9 lines 5-35) mounted above and configured to detect a peripheral region of the substrate (Fig 1). Further the interferometer end point system comprises a light source and a light detector (Col 10 lines 18-65) and a computer for calculating a spectra (Col 10 line 65 to Col 11 line10) and comparing to a stored characteristic value to determine the endpoint.

Herchen et al do not disclose the detection of the end point from below the substrate. The decision to detect end point from top or bottom side, however, depends upon the orientation of etching and type of multilayers, on the substrate and convenience of mounting hardware.

Mihashi et al disclose detecting end point from the bottom side of the substrate (Abstract and Fig 1).

Therefore it would have been obvious to one of ordinary skill in the art at the time of invention to detect end point from below the substrate since decision to detect end point from top or bottom side depends upon the orientation of etching and type of multilayers, on the substrate and convenience of mounting hardware.

Further this is only a rearrangement of parts. Rearrangement of parts was held to have been obvious. *In re Japikse* 86 USPQ 70 (CCPA 1950). Similarly reversal of parts was held to have been obvious. *In re Gazda* 104 USPQ 400 (CCPA 1955).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ram N. Kackar whose telephone number is 571 272 1436. The examiner can normally be reached on M-F 8:00 A.M to 5:P.M.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571 272 1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Ram Kackar Examiner AU 1763

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